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PATENT NUMBER and
ISSUE DATE

U.S. UTILITY Patent Application

APPL NUM 10085092	FILING DATE 03/01/2002	CLASS 392 219	SUBCLASS 118	GAU 3712 1725	EXAMINER Fugwa
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**APPLICANTS: Shimizu Masahiro; Yazawa Minoru;

**CONTINUING DATA VERIFIED:

** FOREIGN APPLICATIONS VERIFIED:

JAPAN 2001-058266 03/02/2001
JAPAN 2001-059293 03/02/2001
JAPAN 2001-072317 03/14/2001

PG-PUB DO NOT PUBLISH ☐

RESCIND ☐

Foreign priority claimed ☒ yes ☐ no
35 USC 119 conditions met ☒ yes ☐ no
Verified and Acknowledged Examiners's initials

ATTORNEY DOCKET NO

07043.0020

TITLE : Heat treatment apparatus using a lamp for rapidly and uniformly heating a wafer

U.S. DEPT. OF COMM/PAT. & TM-PTO-436L (Rev. 12-94)

NOTICE OF ALLOWANCE MAILED		CLAIMS ALLOWED	
		Total Claims	Print Claim for O.G.
ISSUE FEE		DRAWING	
Amount Due	Date Paid	Sheets Drwg.	Figs.Drwg. Print Fig.
<input type="checkbox"/> TERMINAL DISCLAIMER		Primary Examiner	
		PREPARED FOR ISSUE	
		Application Examiner	
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